

## Correction to: Cold Spraying of Armstrong Process Titanium Powder for Additive Manufacturing

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**Correction to:**  
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We regret that in the original article the values in Table 2 are for copper, not for titanium.

The values of titanium are listed in the table that replaces Table 2 of the original paper.

However, it should be noted that the modeling was done with the correct data for titanium and only Table 2 in the original paper had the error.

**Table 2** Material parameters used for model [taken from (Ref 51, 63)]

Symbol	Description	Value
$P$	Density ( $\text{g cm}^{-3}$ )	4.51
$\mu$	Shear (GPa)	30
$A$	JC (MPa)	806
$B$	JC (MPa)	481
$C$	JC	0.0194
$n$	JC	0.319
$m$	JC	0.665
$\varepsilon_0$	JC	1
$c_0$	EOS ( $\text{m s}^{-1}$ )	4950
$s$	EOS	7
$\Gamma_0$	EOS	1.184
$T_m$	Melting point (K)	1923
$c_v$	Heat capacity ( $\text{J K}^{-1} \text{Kg}^{-1}$ )	528
$K$	Thermal conductivity ( $\text{W K}^{-1} \text{m}^{-1}$ )	11.4

Note: In the description, *JC* stands for Johnson-Cooks, *EOS* for Equation of State

The original article can be found online at <https://doi.org/10.1007/s11666-016-0489-2>.

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